

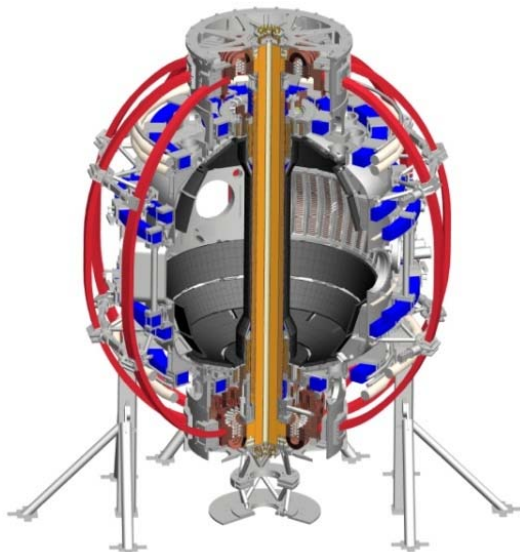
Erosion and re-deposition of lithium and boron coatings under high-flux plasma bombardment

Tyler Abrams

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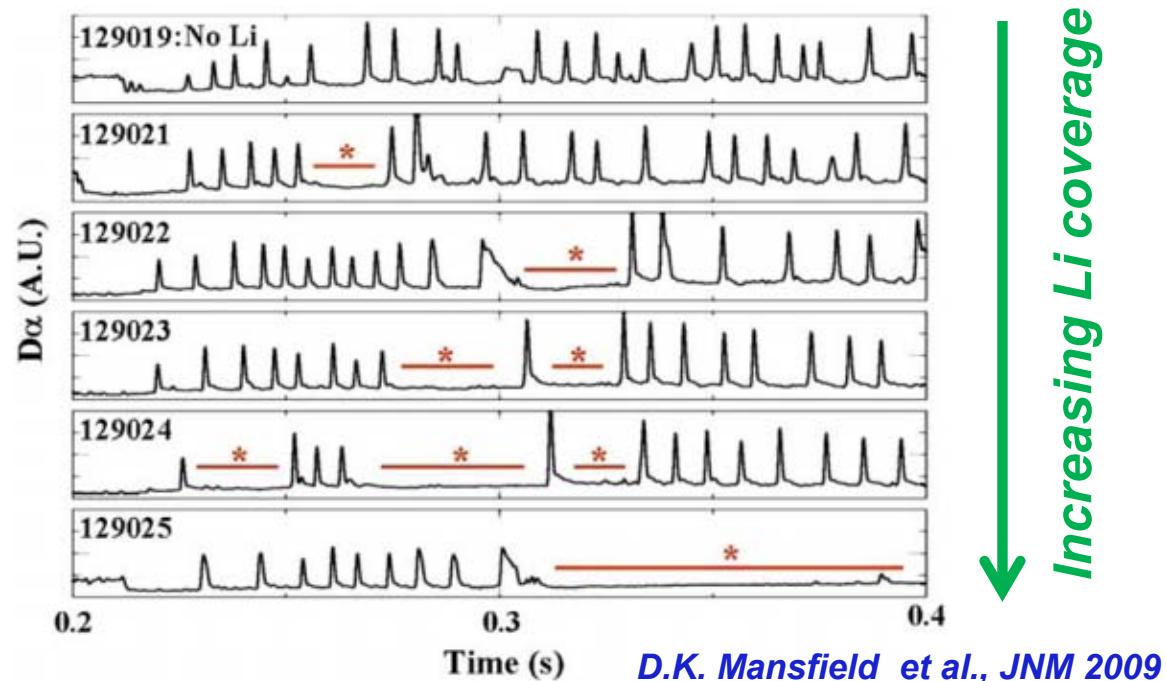
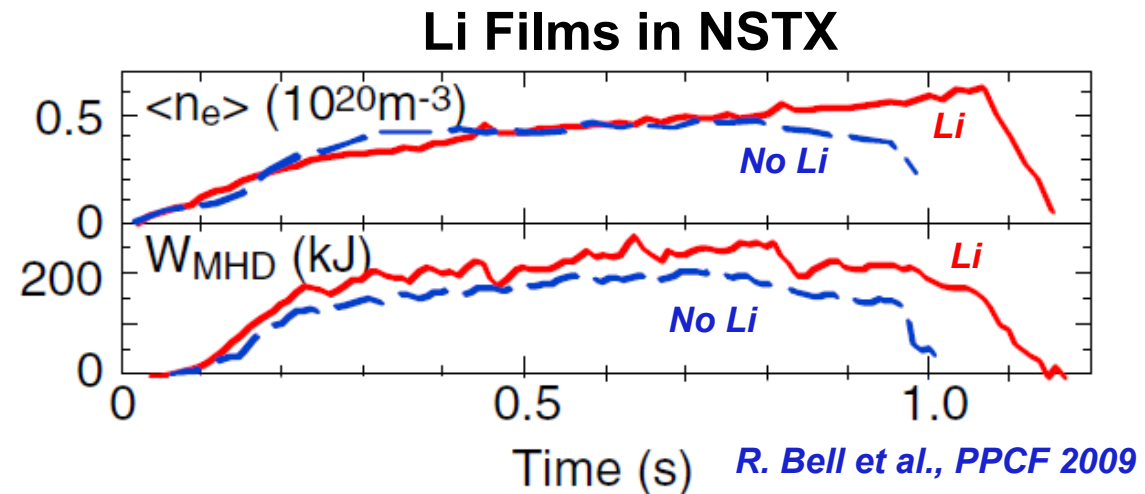
*Coll of Wm & Mary
Columbia U
CompX
General Atomics
FIU
INL
Johns Hopkins U
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Lehigh U
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ASCR, Czech Rep*

Lithium improves plasma performance and protects underlying substrates

- Improved performance:
 - Increased n_e , W_{MHD}
 - ELM reduction
- Li protects even fragile porous substrates from high heat fluxes^{a,b}
- Liquid Li is an alternative to W for a DEMO PFC
 - Self-healing under plasma bombardment
 - Eroded material can be replenished by flow



^aG. Mazzitelli et al., FED 2010

^bT. Abrams et al., JNM 2013

Previous results on flow-flux devices suggest Li erosion may be unacceptably high at elevated temperatures

- Li erosion rate scales with temperature
 - Evaporation (Langmuir Law)
 - T-dependent sputtering (PISCES-B, IIAX, DIII-D)

- Thermal-spike model^a:

$$Y(T_{Li}) = \frac{A}{\sqrt{kT_{Li} + B}} \exp\left(\frac{-1.59 \text{ eV}}{\sqrt{kT_{Li} + B}}\right)$$

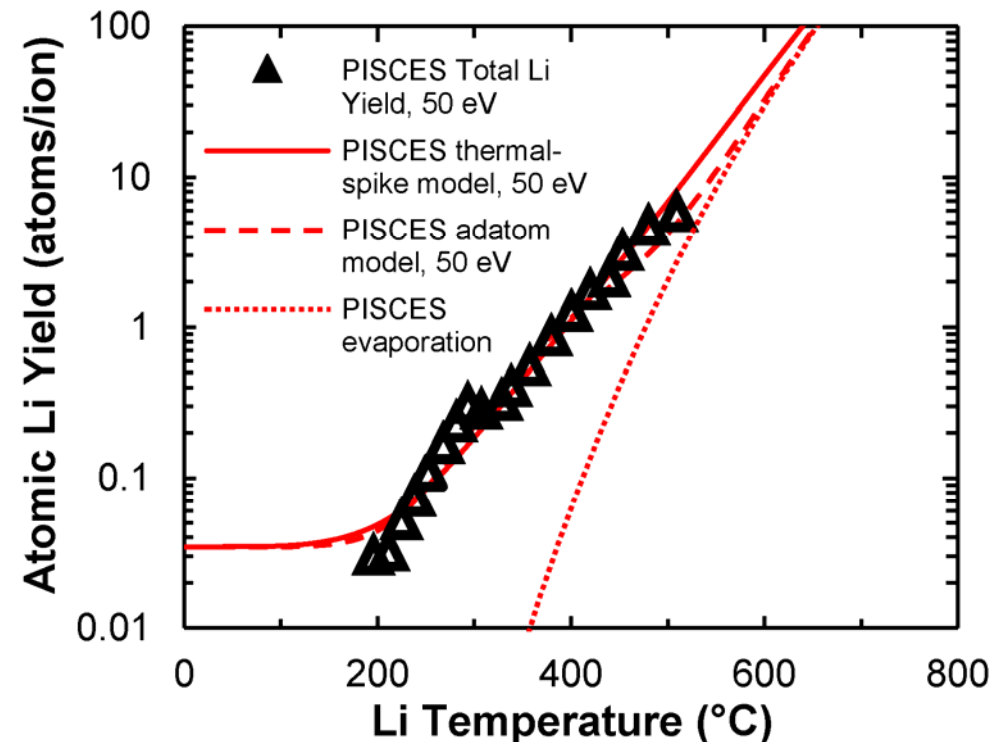
A, B: Fitting parameters
k: Boltzmann's constant

- Adatom-sublimation model^b:

$$Y(T_{Li}) = \frac{Y_{ad}}{1 + A \exp\left(\frac{E_{eff}}{kT_{Li}}\right)}$$

Y_{ad}, A, E_{eff}: Fitting Parameters

**Atomic Li Yield vs. Li Temperature
Measured on PISCES-B**

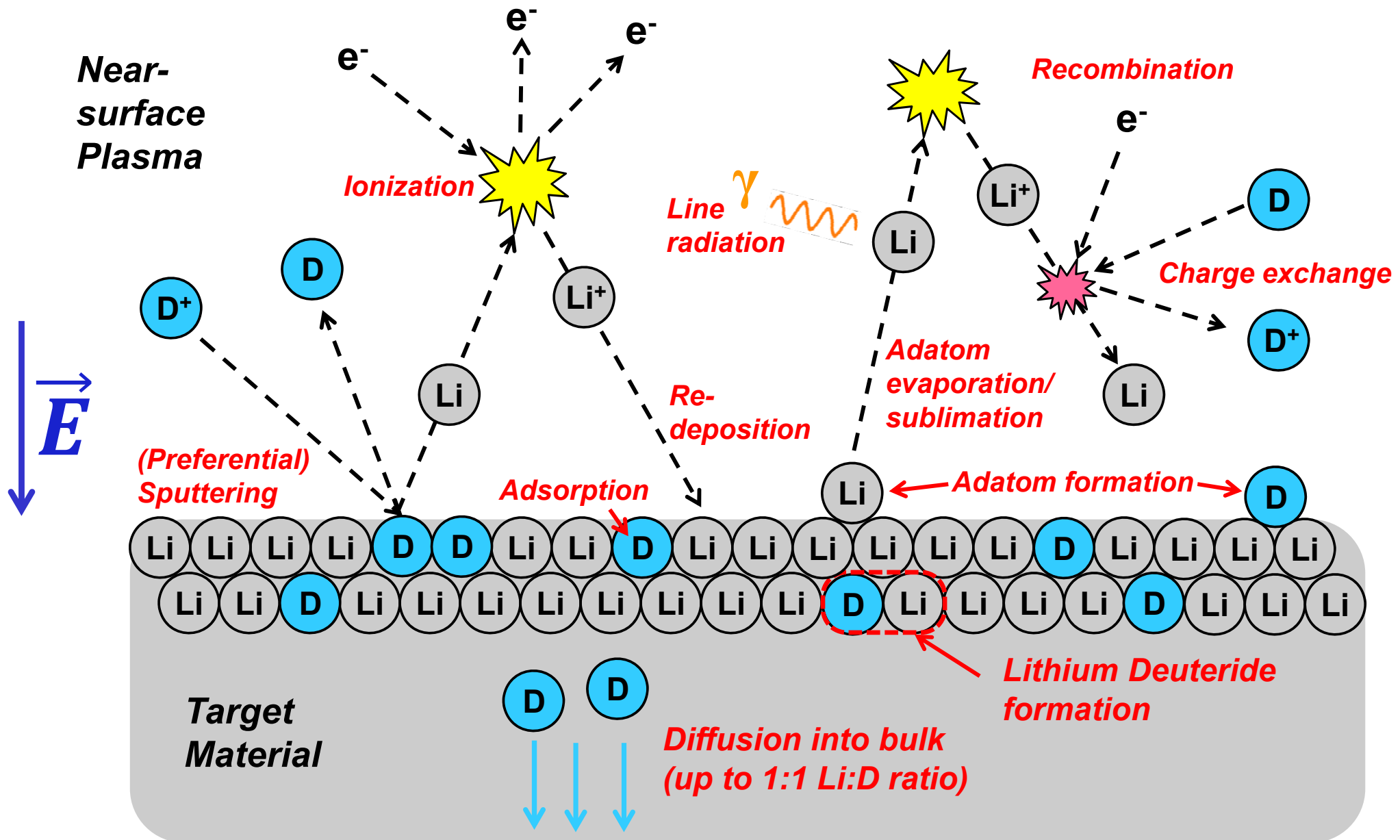


^aJ.P. Allain et al., Phys Rev B 2007

^bR.P. Doerner et al., J. App. Phys. 2004

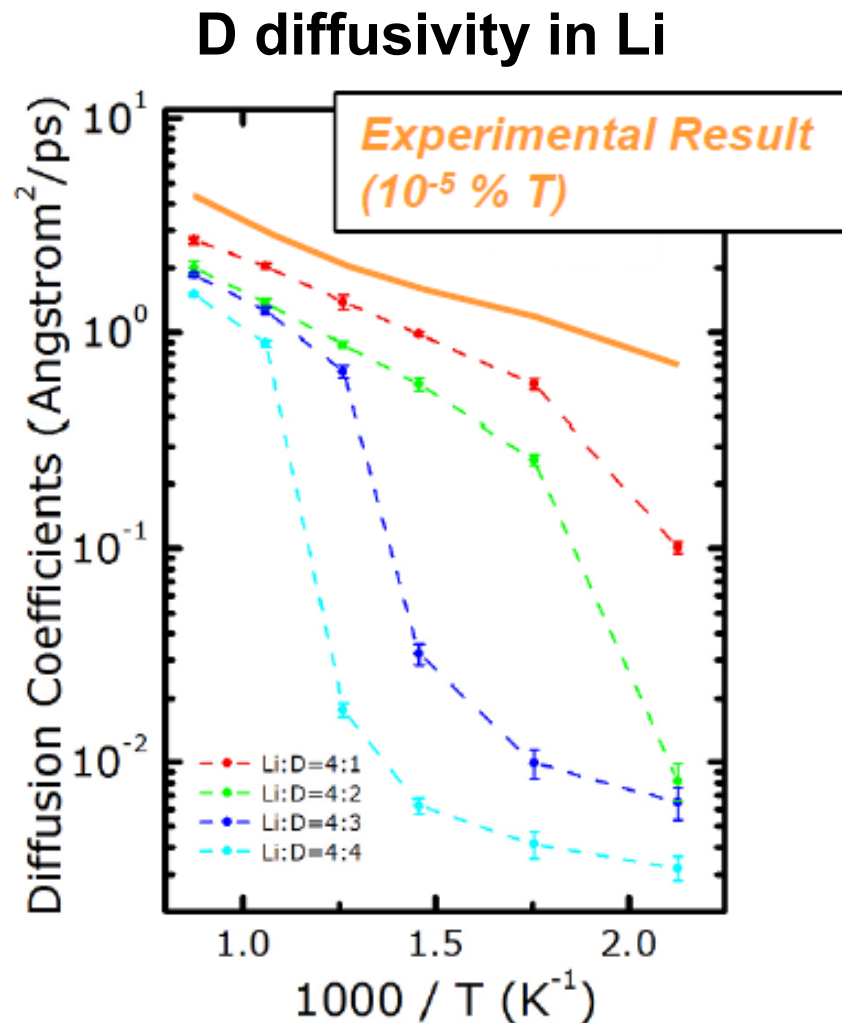
R.P. Doerner et al., JNM 2001

Many processes are involved in the D-Li PMI



D diffusion in Li has been characterized using molecular dynamics (MD) simulations

- Recent MD simulations^a have calculated D diffusivity in Li vs. temperature and D/Li concentration (β)



- Diffusion coefficients decrease strongly vs. D/Li concentrations
- Evidence of LiD solidification for 100% LiD
 - LiD melting temp: 965 K ($1000/T_{\text{melt}} = 1.04$)

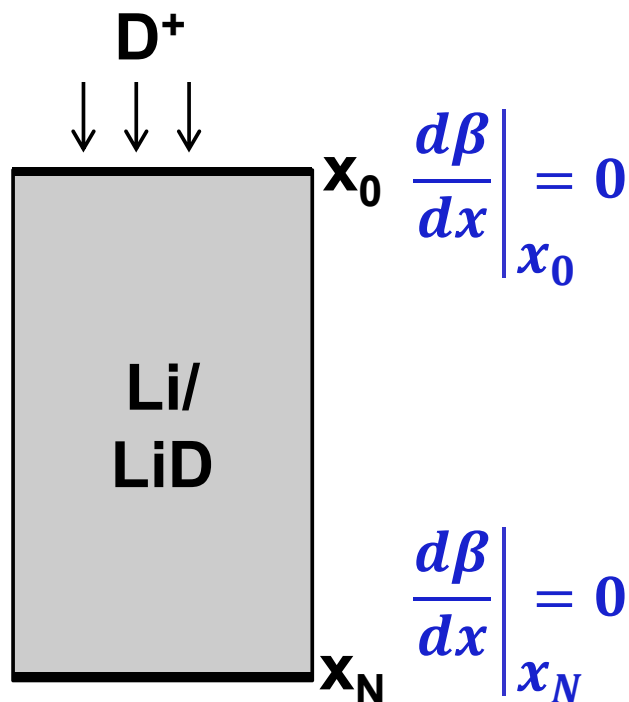
^aM. Chen and E.A. Carter, Nuc. Fusion, in prep.

^bH. Moriyama et al., JNM 1992

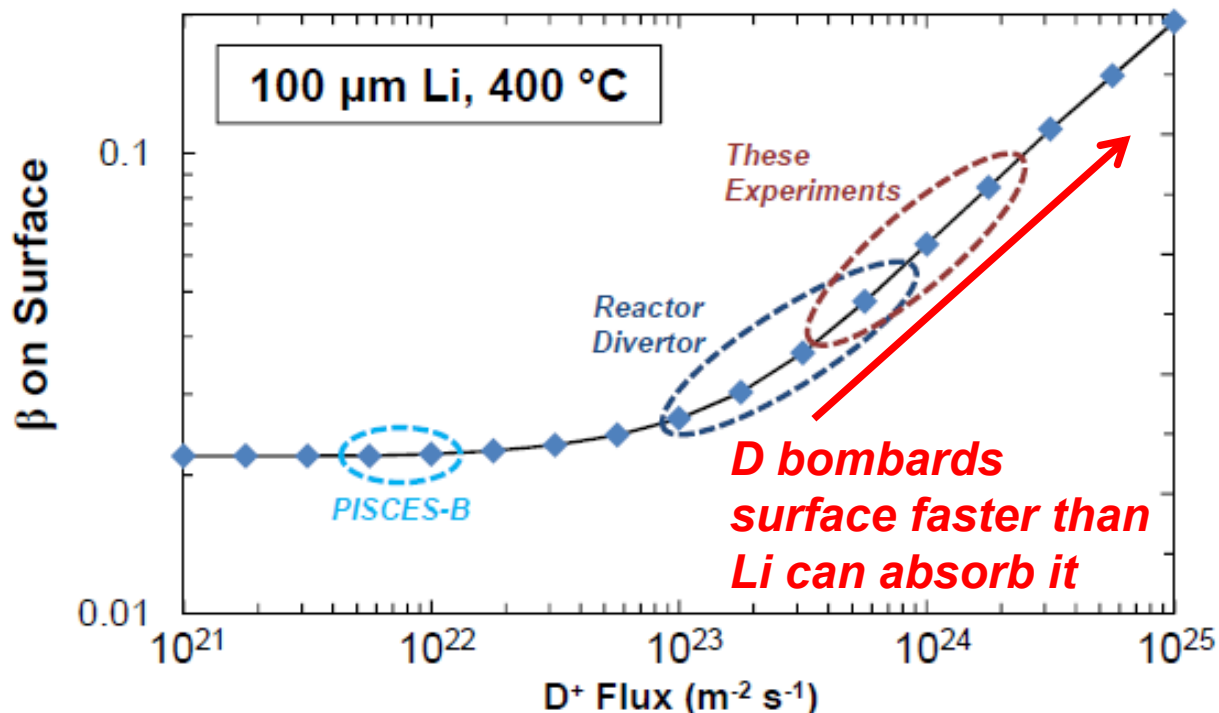
Time evolution of Li:D concentration can be determined for any plasma/surface conditions

- Solve 1-D diffusion equation with time and space-dependent diffusion coefficients
- D assumed implanted uniformly in top 5 nm of material

$$\frac{d\beta(x, t)}{dt} = D(\beta) \frac{d^2\beta(x, t)}{dx^2}$$

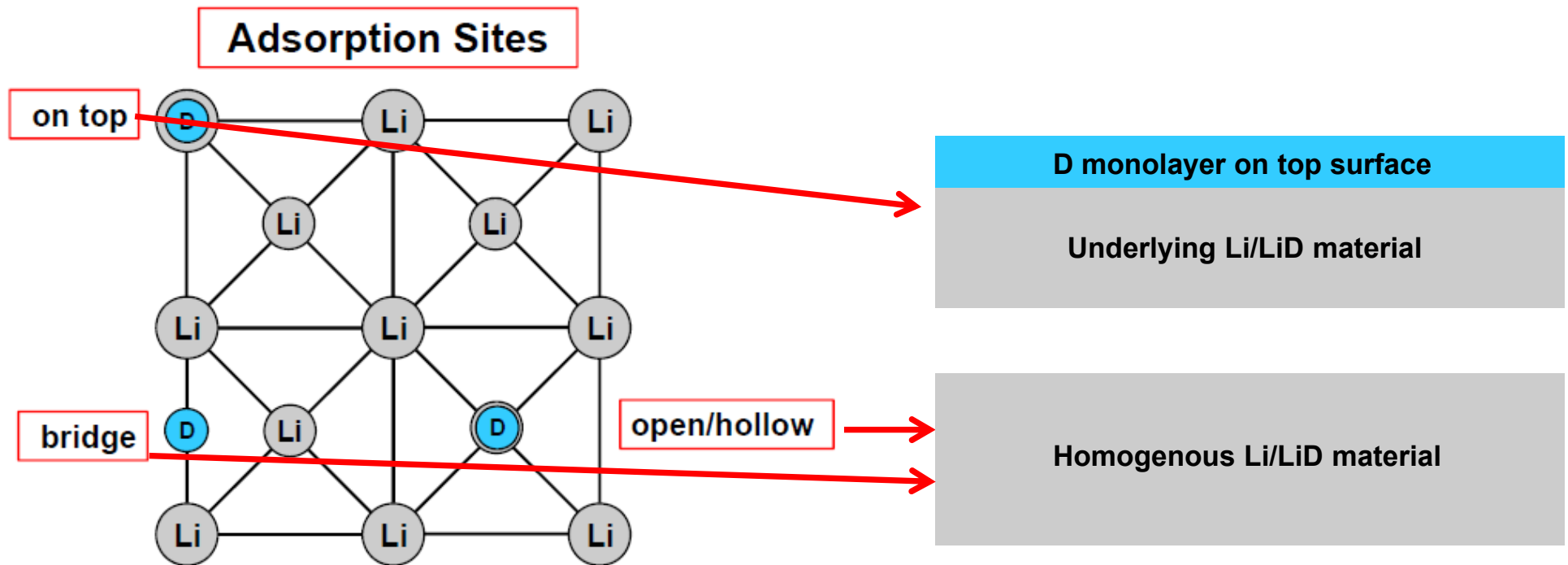


Surface D / Li concentration after D fluence of 10^{23} m^{-2}



How does D concentration on Li surface affect sputtering?

- D absorption reduces Li sputtering in two ways:
 - **Preferential sputtering:** less atoms available to sputter
 - **Chemistry:** SBE* is higher for LiD (2.26 eV) vs. Li (1.67 eV)
- D atoms can adsorb on a Li surface in several different sites
 - Motivates two different models of a Li/LiD surface

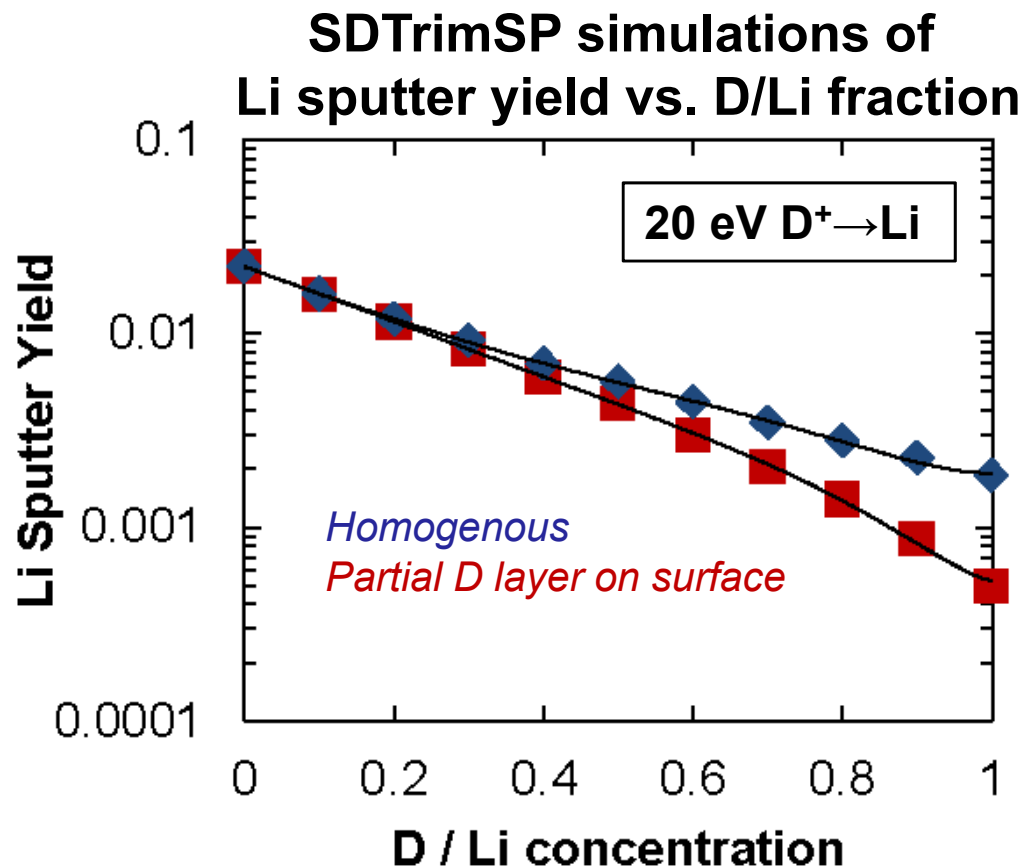


*Assumed equal to heat of sublimation

Sputtering on a Li/LiD surface can be simulated with SDTrimSP binary collision approximation (BCA) code^a

- Preferential sputtering is directly incorporated
- Chemical effects simulated by interpolation of SBEs:

$$\text{SBE}_{\text{eff}} = (1 - \beta)\text{SBE}_{\text{Li}} + \beta\text{SBE}_{\text{LiD}}$$



- D impurities in Li results in **strong reduction of $Y_{\text{D} \rightarrow \text{Li}}$**
- Reduction for 100% LiD:
 - **~10x** in homogenous case
 - **~40x** w/ D monolayer on LiD surface
- Empirically fit $f(\beta)$

^aA.Mutzke, R.Schneider, W.Eckstein, R.Dohmen, SDTrimSP Version 5.0. IPP Report 12/8, Garching, (2011)

Evaporation of LiD in suppressed relative to pure Li

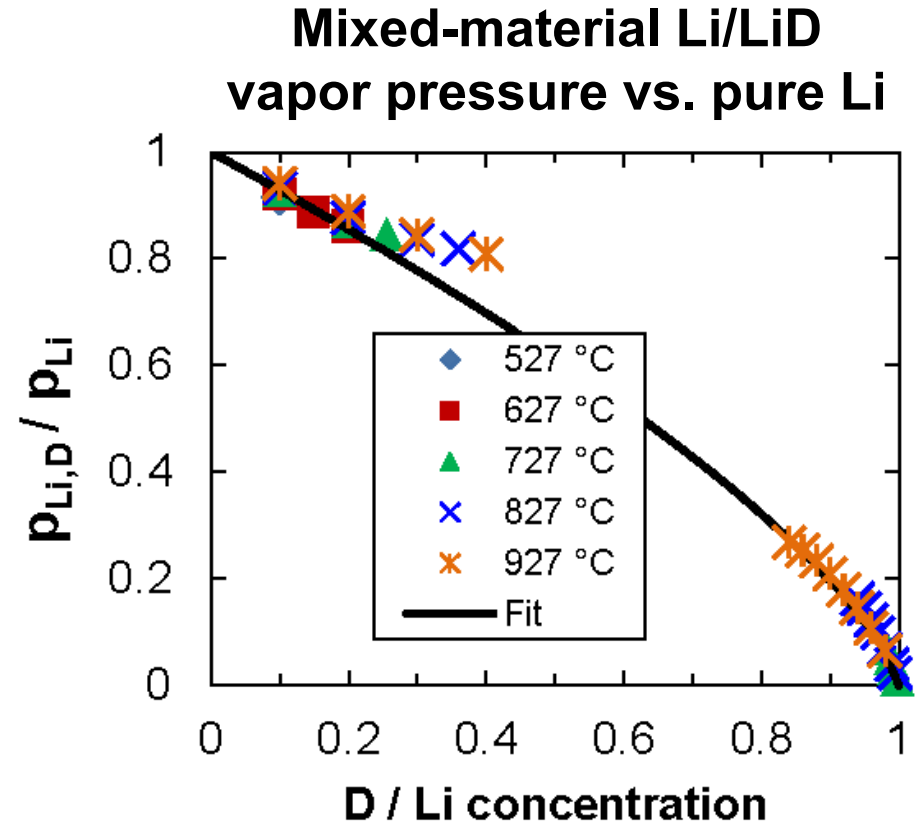
- Li vapor pressure above Li/LiD mixtures is reduced relative to pure Li
- Reduction factor is independent of temperature

$$\Gamma_{\text{evap}}(T_{\text{Li}}) = \frac{p_{\text{Li,D}}}{\sqrt{2\pi m_{\text{Li}} k T_{\text{Li}}}}$$

Γ_{evap} : Evaporative Li flux
 p_{Li} : Li vapor pressure
 m_{Li} : Li mass (6.941 amu)

- Empirical fit formula:

$$\frac{p_{\text{Li,D}}}{p_{\text{Li}}} = (1 - \beta)^{0.705}$$

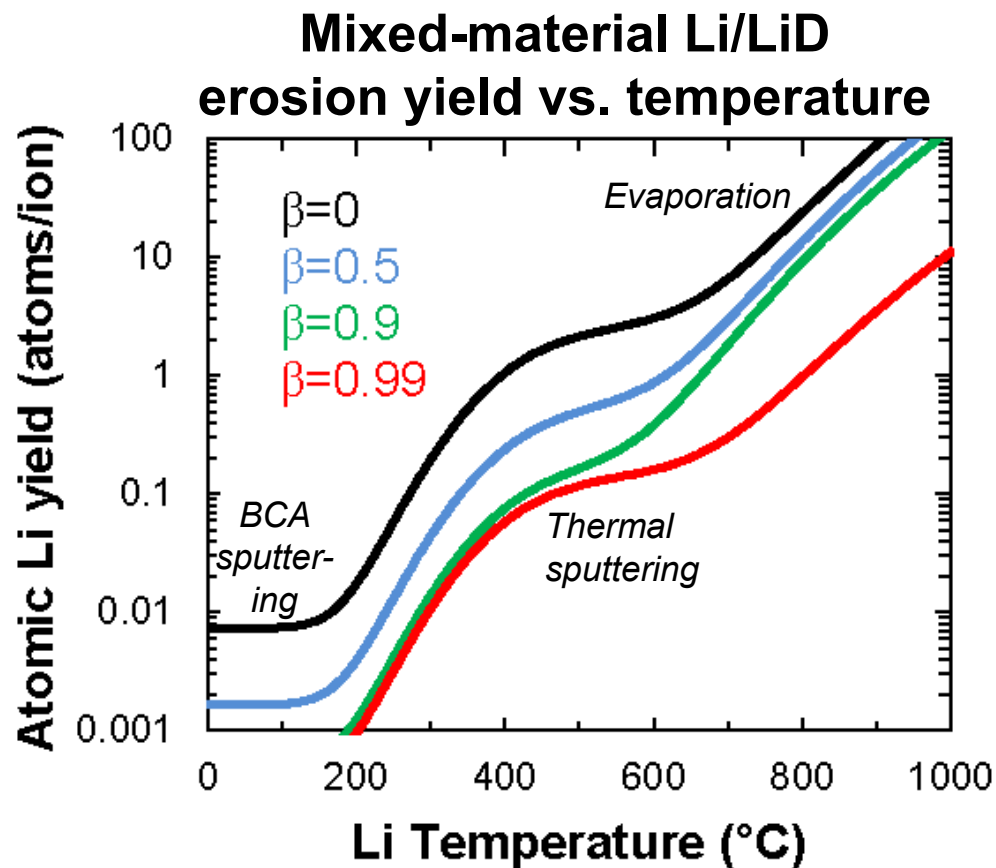


E.E. Shpil'rain et al., 1987

Corrected Li erosion model is a function of Li temperature and D concentration in the Li

$$\Gamma_{Li}(T_{Li}, \beta, \Gamma_{D+}) = \Gamma_{D+} \underset{\substack{\text{D/Li mixed-} \\ \text{material} \\ \text{reduction} \\ \text{factor}}}{f(\beta)} \left[\underset{\substack{\text{2/3 of} \\ \text{sputtered Li is Li}^+ \\ \text{(re-deposited)}^a}}{\frac{Y_{coll}}{3}} + \underset{\substack{\text{Thermally-enhanced} \\ \text{sputtering} \\ \text{(adatom-evaporation model)}}}{\frac{Y_{ad}}{1 + A \exp\left(\frac{E_{eff}}{k_B T_{Li}}\right)}} \right] + \underset{\text{Evaporation}}{\frac{p(T_{Li}, \beta)}{\sqrt{2\pi m_{Li} k_B T_{Li}}}}$$

Total Li erosion (m⁻² s⁻¹)

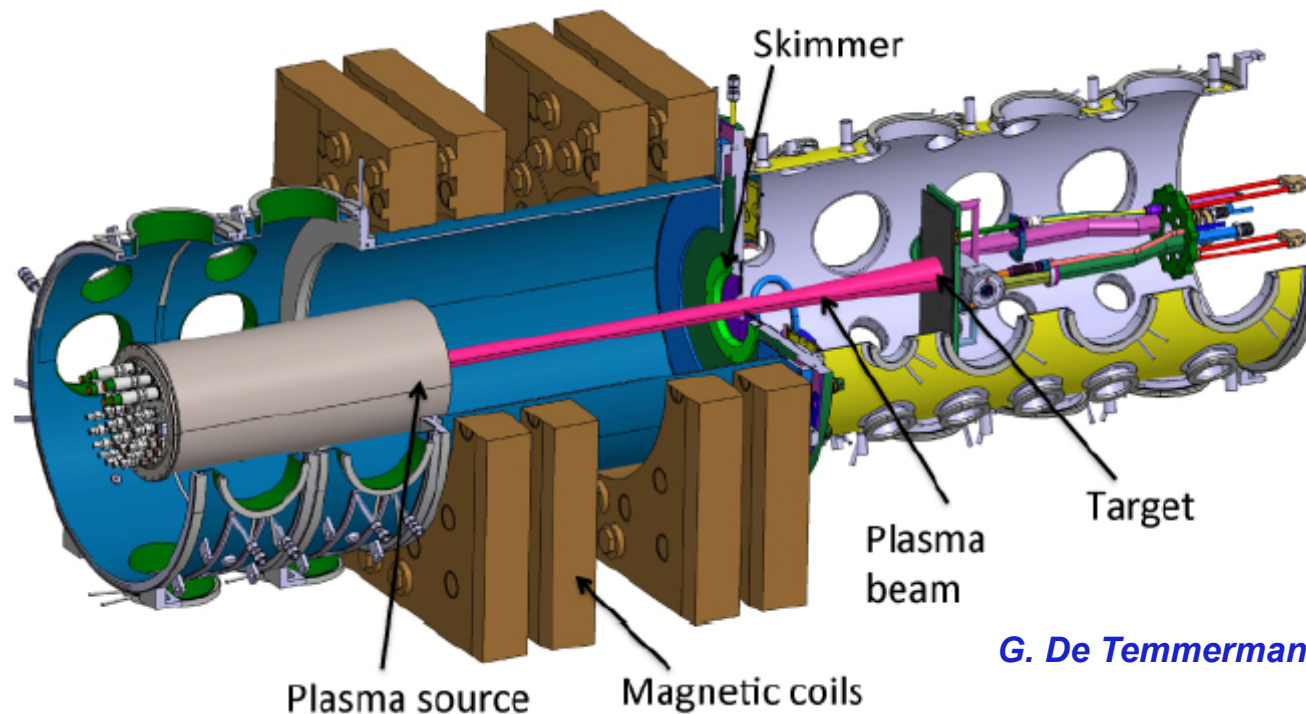


- Assume Y_{ad} and Y_{coll} are both reduced by $f(\beta)$
 - Average of the **homogeneous LiD** and **surface D monolayer** models
- Adatoms on a liquid?
 - Have been observed in MD simulations^b
 - A is related to adatom lifetime τ
 - $\tau_{Li} \gg \tau_{Be}$ (less vacancies on liquid)

^aK. Nordlund et al. Lett. Nat. 1999

^bJ.P. Allain et al., Phys. Rev. B 2007

Model tested and analyzed in Magnum-PSI linear plasma device



G. De Temmerman et al., FED 2013

- $\Gamma_{D+} \lesssim 2 \cdot 10^{24} \text{ m}^{-2}\text{s}^{-1}$, $T_e \lesssim 3 \text{ eV}$, $n_e \lesssim 8 \cdot 10^{20} \text{ m}^{-3}$
- 5-10 s pulses, $B = 0.25 \text{ T}$ at target, 20-40 V bias
- Normal incidence: **no magnetic pre-sheath**
- Two sample types (both 2.5 cm diameter)
 - Evaporated Coatings ($\leq 1 \text{ } \mu\text{m}$)
 - Shallow Li cups (0.1 – 1.0 mm)

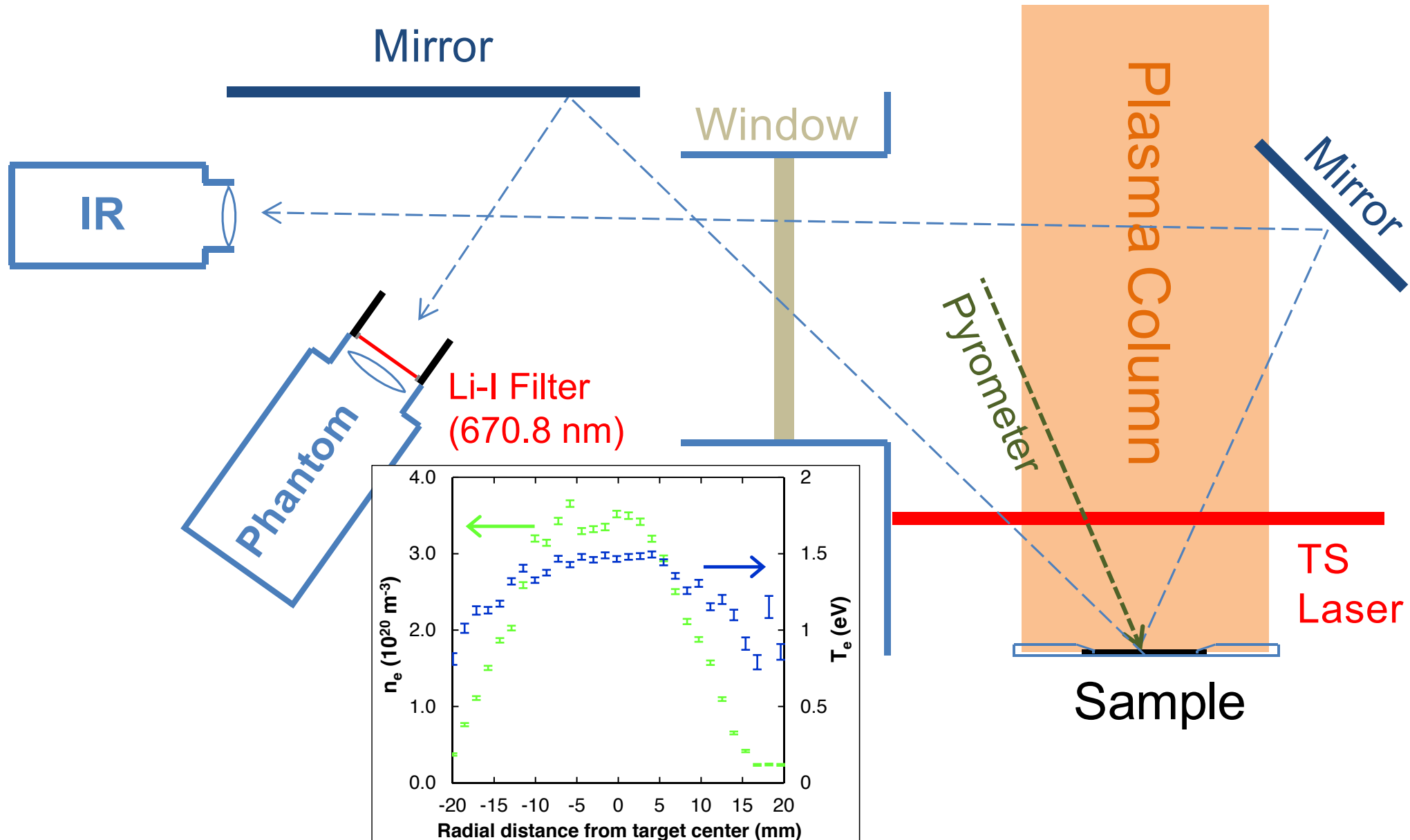
New procedure developed for loading 0.1-1.0 mm thick Li targets in Magnum-PSI sample holder

1. Li melted into sample wells inside Ar glove box
2. Sealed with SS shim stock covers & heat-seal mylar bags
3. SS cover remained on sample during mounting
4. Li exposed to atmosphere for 20-30 s between cover removal & vessel pumpdown
5. Ar plasma discharges used to remove oxide coating from Li



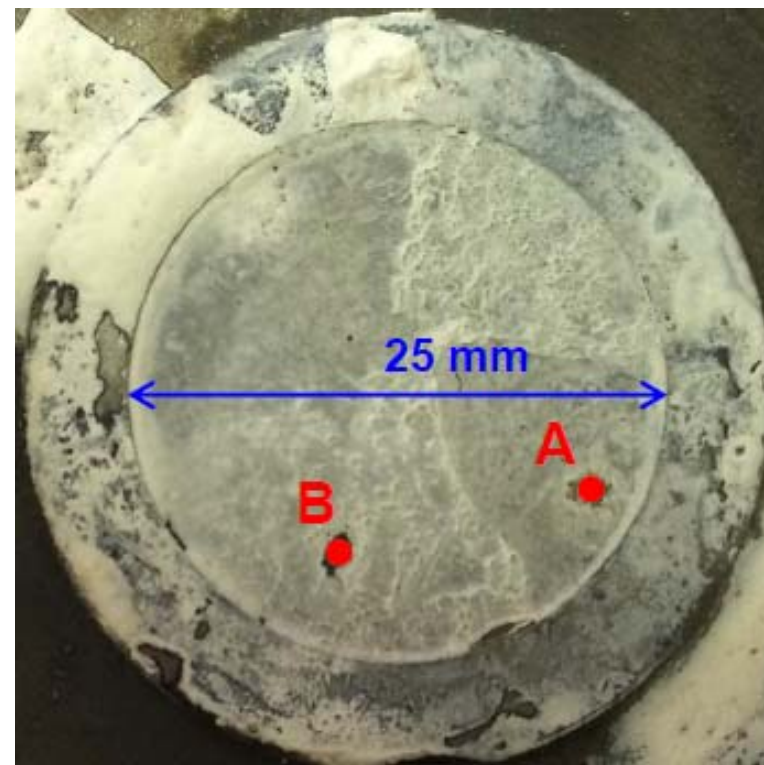
Four Li samples melted into wells on a SS prototype plate (two with shim stock covers)

Diagnostic suite provides measurements of plasma n_e/T_e , Li-I impurity radiation, and sample temperature



Macroscopic melt motion observed during Ar plasma cleaning of thick Li coatings

- Quickly reduces coating from its initial value of 500 μm
- Resulting thickness of Li coating measured for a sample exposed to a single Ne plasma shot
 - Measured via confocal microscopy
 - Assumed that coating expands along z direction only during conversion to Li carbonate
- Motivates modeling of $\beta(t)$ for reduced Li thicknesses



Position (mm)	Point A thickness (μm)	Point B thickness (μm)
0.5	25	56
1.0	30	167
1.5	39	125
2.0	40	132
2.5	7	156

Mixed-material Li erosion model can be tested by varying

1) ion species 2) total D fluence

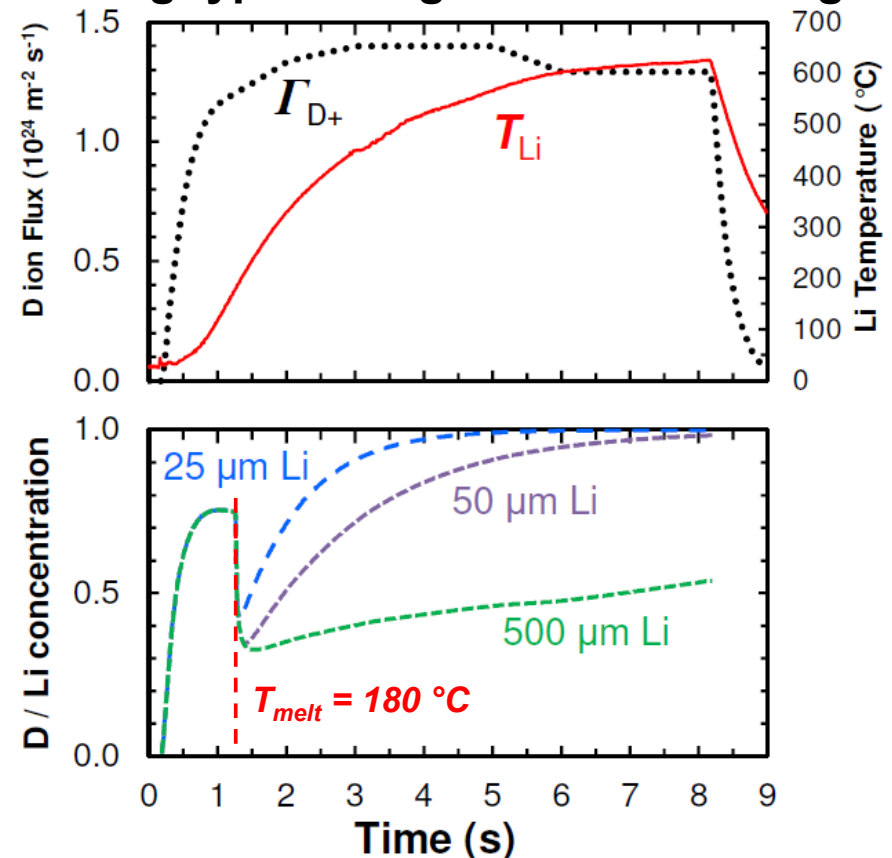
1. Measure Li erosion rate during Ne plasma bombardment

- Ne is not retained in or chemically reactive with Li
- Thus model predicts no reduction in erosion rate at high fluxes

2. Measure Li erosion rate as β changes dynamically

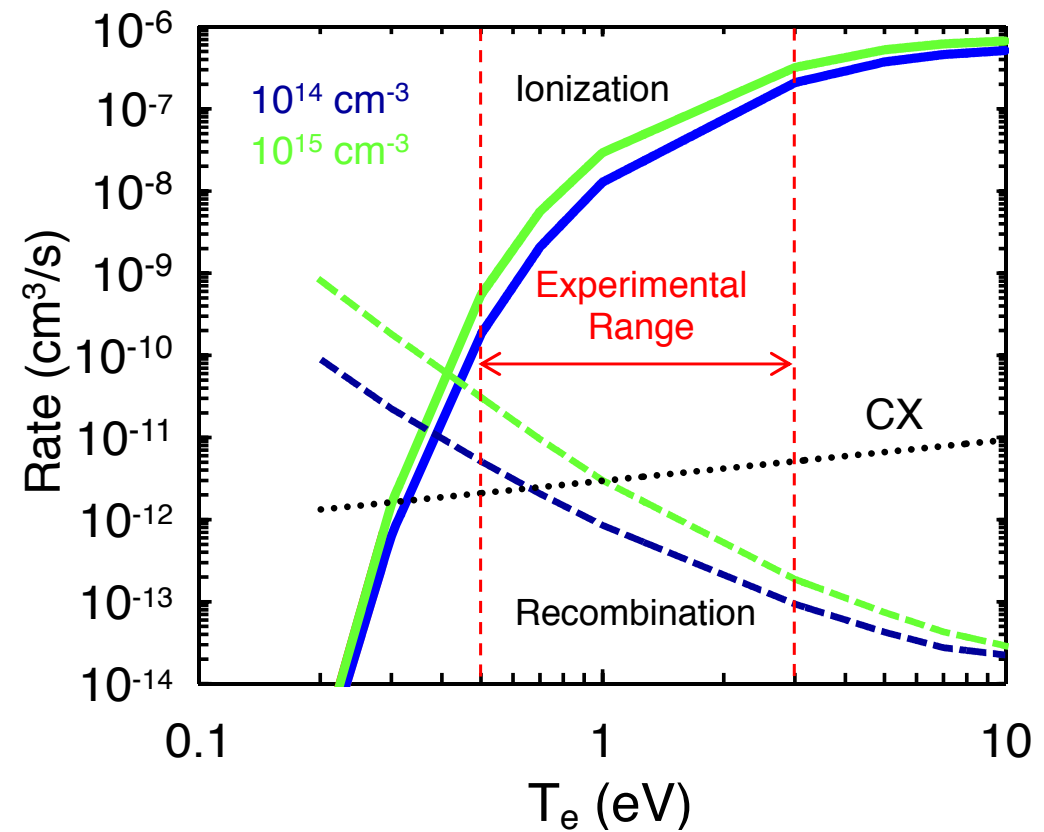
- $\beta(t)$ can be predicted using 1-D diffusion model for D in Li
- Significant melt motion led to uncertainty in time evolution of Li thickness
- Time evolution of β for various thicknesses were tested

Time Evolution of β , Γ_{D+} , and T_{Li} during typical Magnum-PSI discharge



Li-I emission rates can be interpreted using atomic data from ADAS collisional-radiative model*

Assumption	% Error
Collisional-radiative model	~0.1
Steady-state	~10 ⁻⁴
No recomb./CX	0.01 – 1
No $\perp$ impurity transp.	0.5 – 5
No second. elect. emiss.	10 ⁻²⁰
No radiation trapping	1 – 10



$$\frac{\partial n_{\text{Li0}}}{dt} + \nabla \cdot (n_{\text{Li0}} v_{\text{Li0}}) = -n_{\text{Li0}} n_e S + n_{\text{Li}+} n_e R + n_{\text{Li}+} n_D C$$

*H.P. Summers, "Atomic Data and Analysis Structure User Manual," 2004. (www.adas.ac.uk)

Li yields inferred from Li-I emission measurements

- Solve Li^0 continuity equation with boundary condition:

$$\nabla \cdot (n_{\text{Li}} \mathbf{v}_{\text{Li}}) = -n_{\text{Li}} n_e S_{\text{Li}}$$

$v_{\text{Li}} = 5200 \text{ m/s (1 eV)}$

$$n_{\text{Li}} v_{\text{Li}} \Big|_{z=0} = Y_{\text{Li}} \Gamma_{D+}$$

Ionization rate coefficient (ADAS)

- Solve for $n_{\text{Li}}(r, z, Y_{\text{Li}})$
- Model for Li-I photons / $\text{m}^2 \text{ s}$:

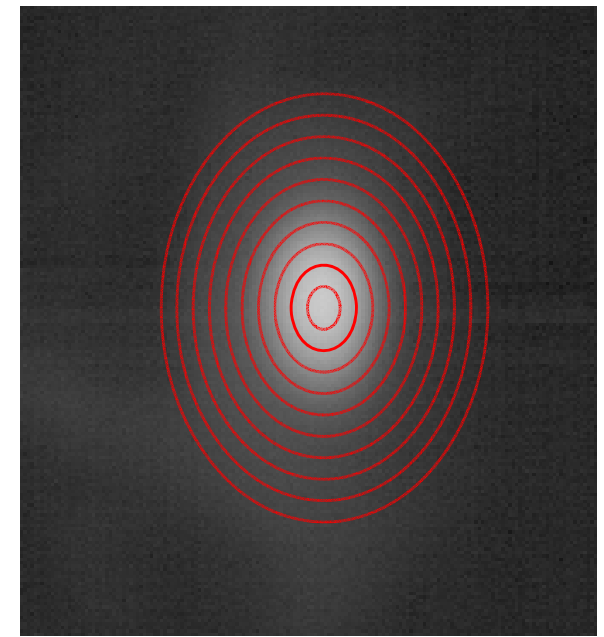
$$I_{\text{Li,model}} = \int_0^{z_0} n_{\text{Li}} n_e P_{\text{Li}} dz$$

Photon emissivity coefficient (ADAS)

- Axially averaged measurement:

$$I_{\text{Li,meas}} = T \frac{\Omega_{\text{pixel}}}{4\pi} \left(\frac{\text{photons}}{s} \right)_{\text{meas}}$$

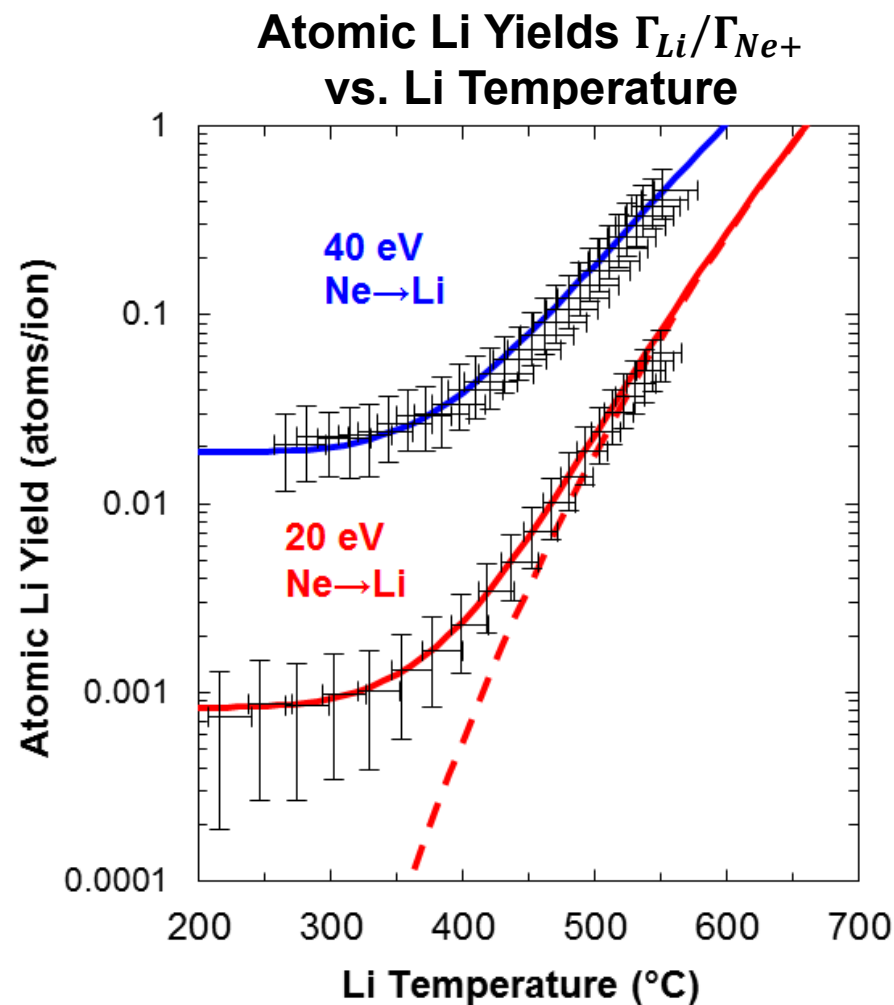
- Set $I_{\text{Li,model}} = I_{\text{Li,meas}} \rightarrow \text{infer } Y_{\text{Li}}$



Axially average Li-I emission

Li yields measured during Ne plasma bombardment are greater than Langmuir Law evaporation

- Suggests erosion model is valid for H-free Li films ($\beta=0$)
- 20 eV Ne $\rightarrow$ Li erosion much lower than 40 eV
 - Model predicts T-dependent sputtering is independent of E_{Ne+}
 - Possible near-threshold effects for Ne
- 40 eV Ne $\rightarrow$ Li consistent with previous results for He $\rightarrow$ Li



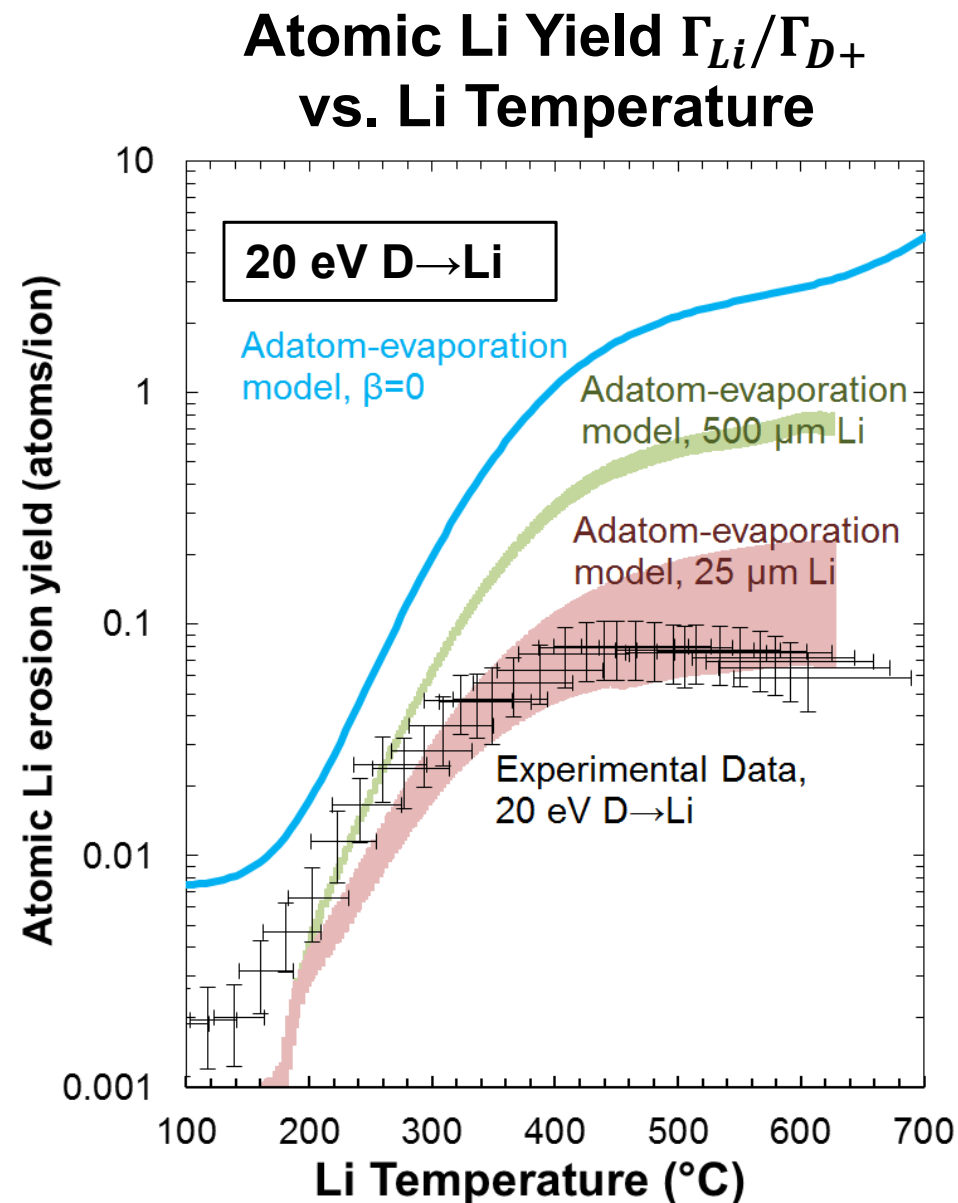
Solid line: Thermal-spike or adatom model (indistinguishable)

Dashed line: Evaporation only

Error bars: Experimental measurements

Li yields measured during D plasma bombardment compared to predictions of adatom mixed-material model

- Error band is distance between homogenous & partial D monolayer surface models
- Adatom mixed-material model captures quantitative evolution of Li erosion rate
- *A priori* assumption that Li thickness reduced to 25 μm



Numerous physics possibilities have been considered

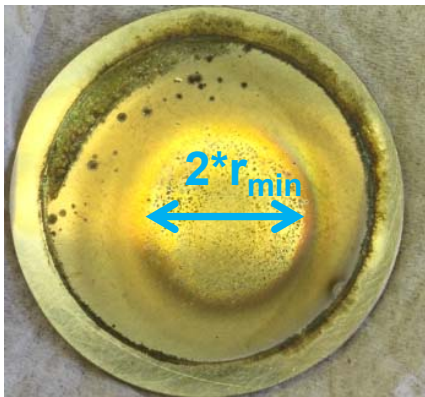
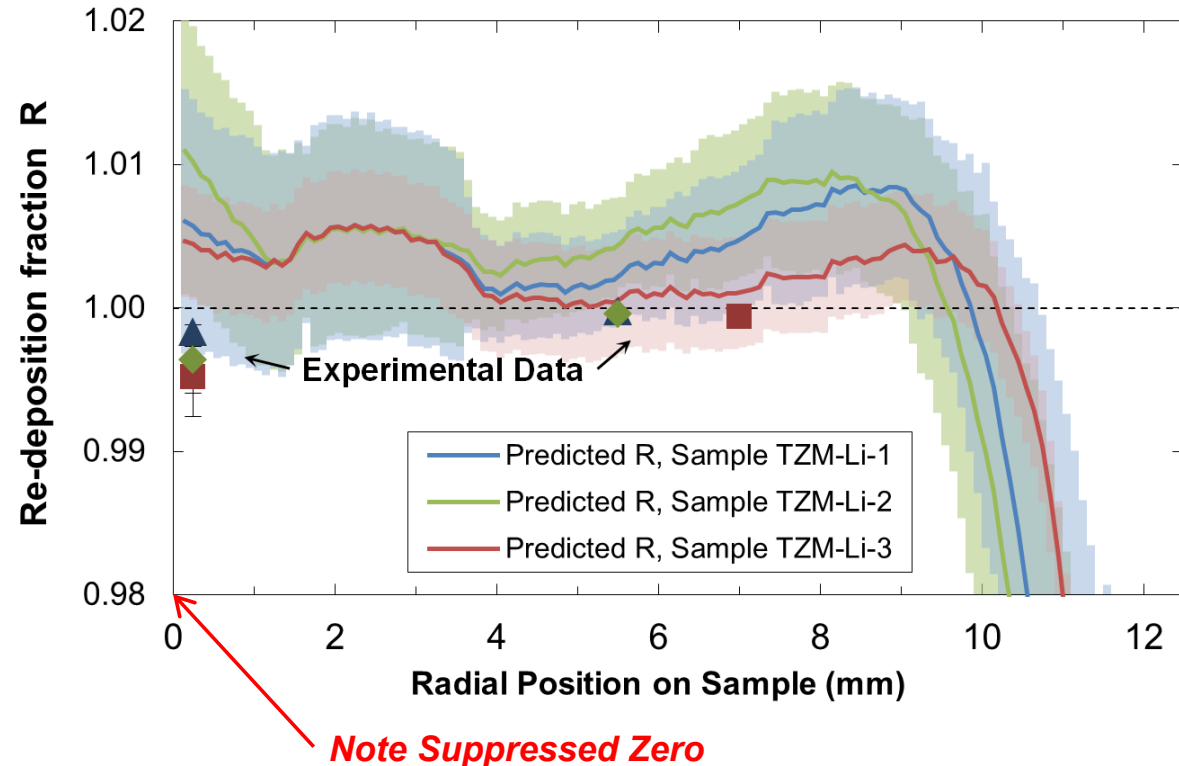
- Recomb./CX small, but would imply an even lower yield
- Γ_{D+} measured fairly constant 4.0-20 mm from target
- Drifts are almost entirely in azimuthal direction
- Results insensitive to v_{Li} (strong ionization)
- Transmission of optics measured before/after experiments
- Self-sputtering is small, would also imply even lower yield

Measured re-deposition fractions R for Li-coated TZM Mo are close to unity, as predicted by modeling

$$R = 1 - \frac{\rho_{\text{Li}}}{\int_0^\tau Y_{\text{Li}} \Gamma_{\text{D}^+} dt}$$

ρ_{Li} = Initial Li areal density

- At $r=0$: τ is the time when Li is depleted from sample center (Li-I emission $\downarrow$)
- At $r=r_{\text{min}}$: τ is the full length of plasma discharges on sample

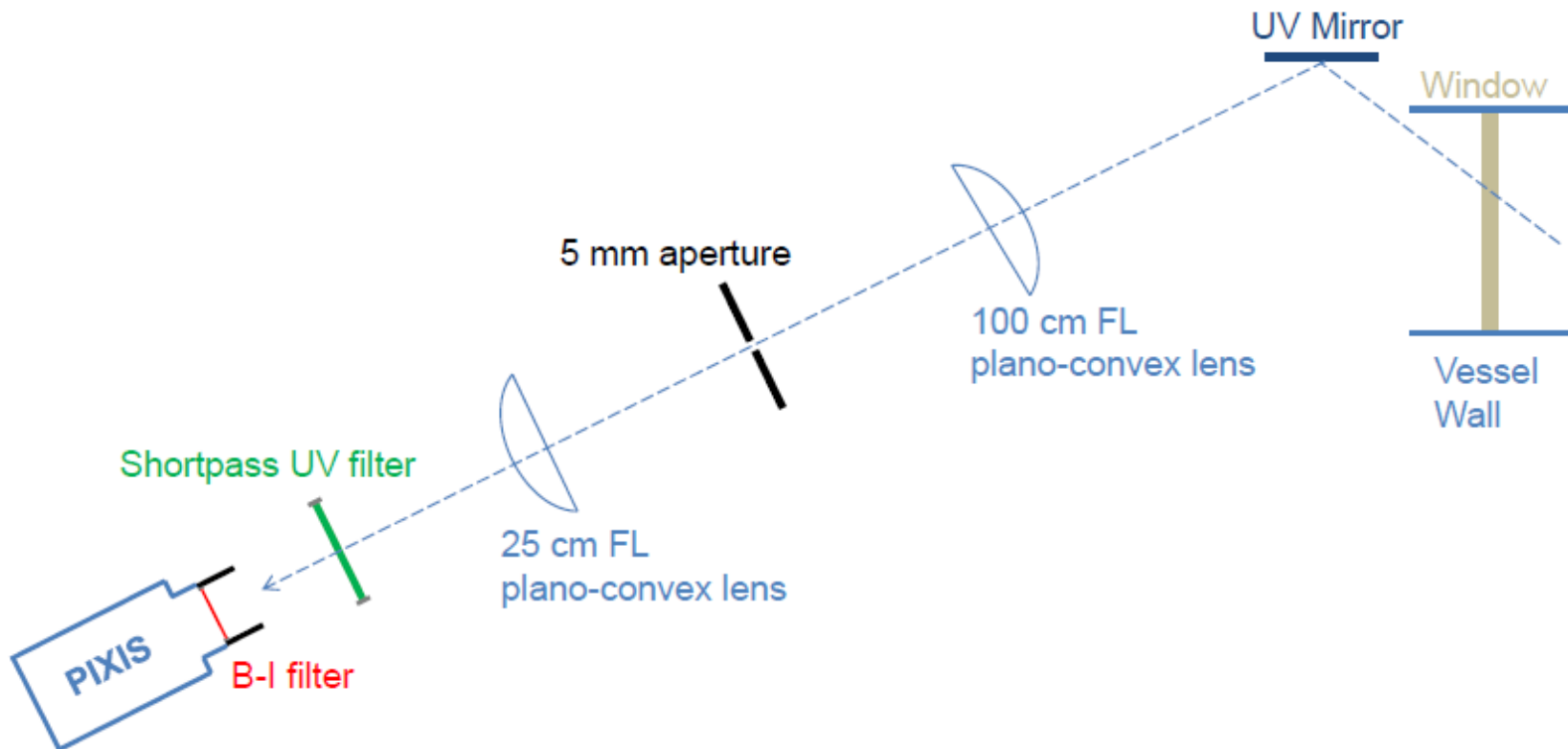


Sample	$n_{e,\text{peak}}$	$T_{e,\text{peak}}$	Li Thickness	Duration
TZM-Li-1	$2.4 \cdot 10^{20} \text{ m}^{-3}$	1.7 eV	190 nm	56 s
TZM-Li-2	$2.6 \cdot 10^{20} \text{ m}^{-3}$	1.5 eV	190 nm	56 s
TZM-Li-3	$3.5 \cdot 10^{20} \text{ m}^{-3}$	1.5 eV	190 nm	42 s

Photograph of Li sample immediately after removal from Magnum-PSI

Preliminary measurements of boron erosion under high-flux D plasma bombardment have also been performed

- 300 nm B layers sputter-coated on TZM Mo
- No strong B lines in visible: use **249.7 nm** line
- Imaged with PIXIS 2040-B camera, ~4 Hz, 1 mm² res.
- Similar analysis applied to data using ADAS tables



Preliminary measurements of boron erosion yield are significantly higher than on ion- beam experiments

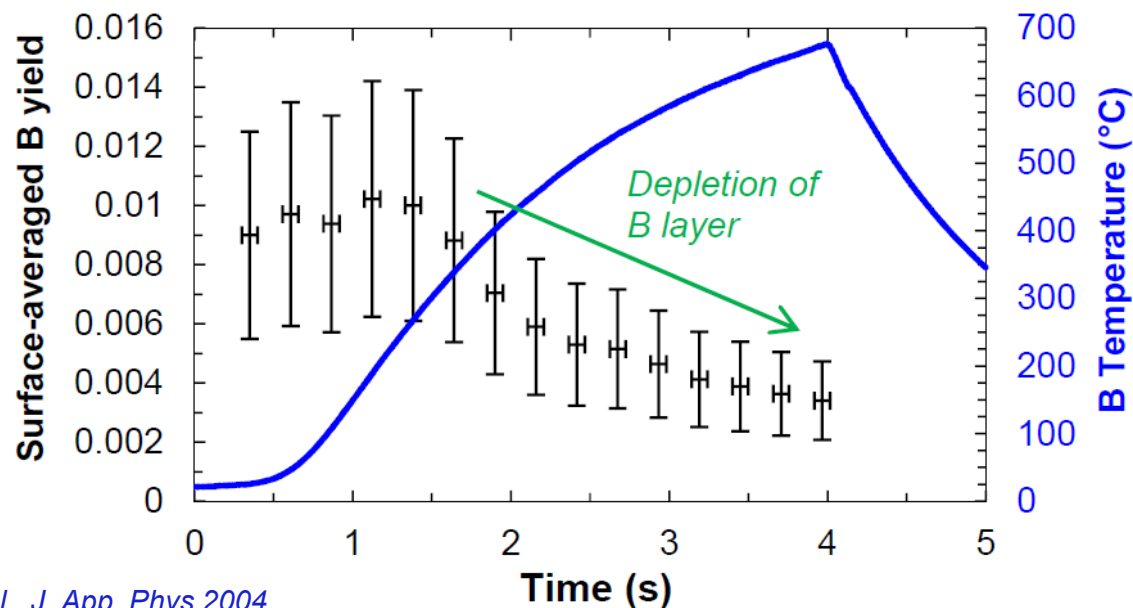
- $\lambda_{iz,B} \gg \lambda_{iz,Li}$
 - "Smearing" of erosion data
 - Can capture total B outflux w/o spatial resolution

- No T dependence, but not expected until $> 0.5 * T_{melt}^{a,b}$
($T_{melt,B} = 2076 \text{ }^{\circ}\text{C}$)

^aR.P. Doerner et al., J. App. Phys 2004
^bH. Maier et al., PSI 2014

- $Y_B \gg$ previous measurement on ion beam device (0.004)
 - SBE of sputtered coating may be lower than bulk B
 - Conversion to boron oxide (B_2O_3) may have occurred
 - Yield could be enhanced via chemical sputtering
 - $Y_{B_2O_3} / Y_B \approx 15$ (TRIM.SP)

Surface-averaged B yield Γ_B/Γ_{D+} vs. B Temperature



Predictions performed of how long a 100 μm Li coating will last under D plasma bombardment in NSTX-U divertor

- Series of 5 s pulses with thermal evolution:

$$T_{\text{Mo}}(t) = T_0 + q \left(\frac{4\alpha_{\text{Mo}} t}{\pi k_{\text{Mo}}^2} \right)^{1/2}$$

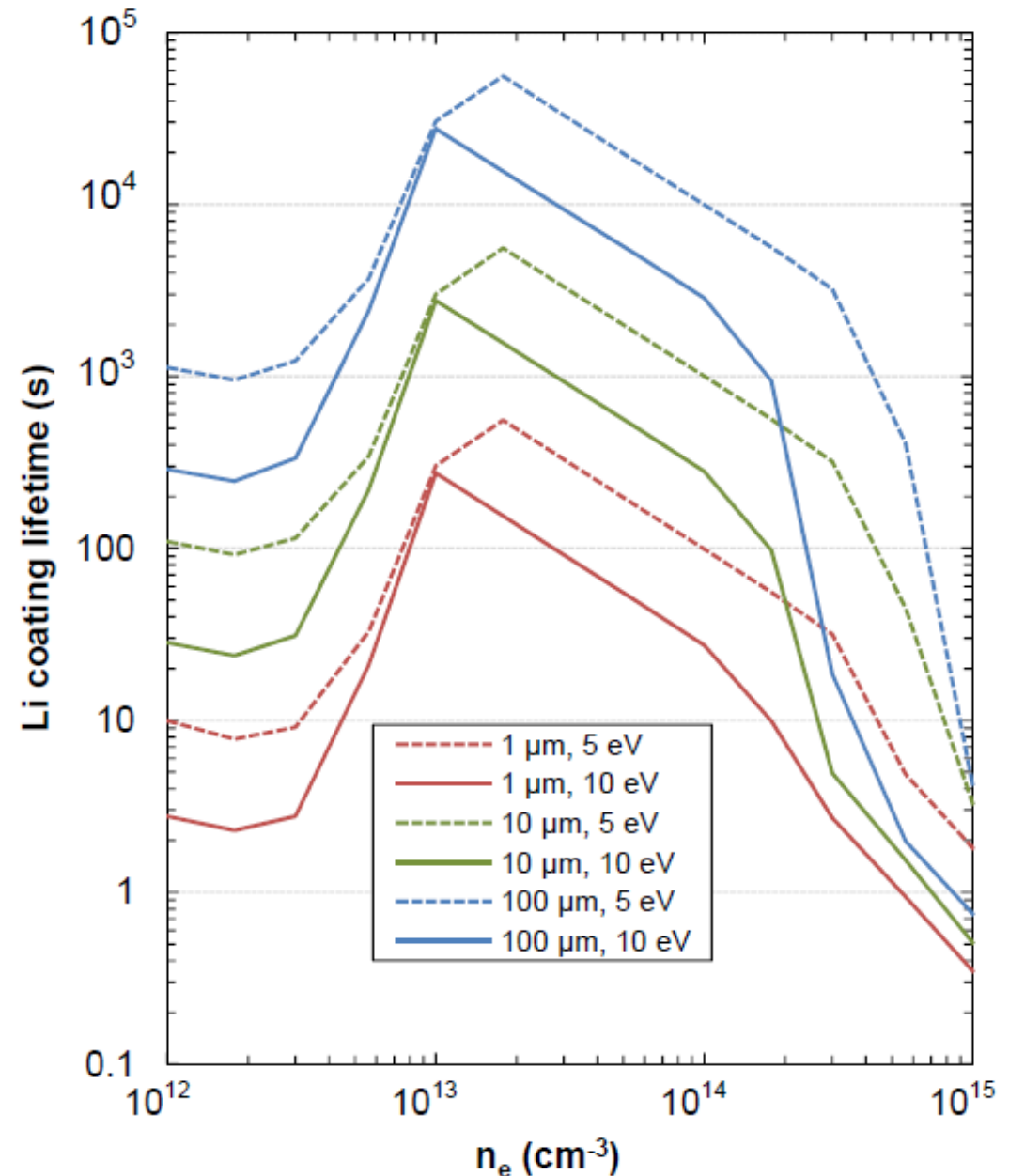
$$q = \frac{1}{2} \gamma n_e T_e c_s \sin \theta$$

$$\gamma = 8 \quad \theta = 3^\circ$$

- Li lifetime calculated by solving for τ :

$$\int_0^\tau Y_{\text{Li}}[T_{\text{Li}}(t), \beta(t), \Gamma_{\text{D}+}] dt = \frac{\rho_{\text{Li}}}{(1 - R)\Gamma_{\text{D}+}}$$

- Note: R calculations are for linear plasma; R_{max} is specified as 0.99



Conclusions

- Adatom-evaporation mixed-material model developed to predict temperature-dependent Li+D erosion rates
- Techniques for inferring time and spatially dependent erosion yields developed using ADAS atomic phys. data
- Erosion yields of Li and B coatings on TZM Mo measured during high-flux bombardment on Magnum-PSI
- Model captures quantitative dependence of Li erosion yield for thick mixed-material Li/D layers
- B erosion measurements using B-I emission performed for the first time using custom-built optics system